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Ontology Mapping of Design Process Knowledge Based on Classification

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Abstract

For the requirements of knowledge reuse in product design process, according to the characteristics of the knowledge representation methods, this paper uses ontology knowledge representation method to construct the product design process knowledge model and gives ontology mapping decision strategy which is based on classification. In the basis of choosing "design department" ontology in human resource management as the heterogeneous ontology of "design organization" ontology in product design process management, lists their concepts set and calculates the similarity of matching concept pairs, finally, outputs the mapping relationship table.

Index Terms: Design process knowledge reuse; Ontology; Mapping; Classification; Similarity calculation

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1. Introduction

Reusing design process knowledge is the precondition of reaching higher-quality and lower-cost in design process. In the knowledge representation, ontology confirms accurate meaning of concepts and their relationships, therefore, ontology is the basis for the information share and reuse.

There are a lot of researches on ontology construction methods at home and abroad. The theory of five ontology construction criterion is more influential which is offered by Gruber. The theory of ontology includes class, hierarchical structure, attributive and relationship which is offered by Natalya. Ontology construction method which is offered by Obrst is similar with Natalya[1]. Previous researches also established ontology models of product design process. However, most ontology models established by using manual pattern and each ontology development team has its own principles and standards, so unification of concepts is mainly realized within a team. Whereas, during the research on the reuse of product design process, the most important thing is the concepts must be coincident and uniform within its field. The optimum method of solving such problem is semantic ontology mapping, which calculates similarity and finds mapping relationship and further establishes the general ontology.

* Corresponding author. E-mail address: hpsx0608@hotmail.com For this reason, this paper constructs design process knowledge ontology model, takes "design department" ontology in human resource management as the heterogeneous ontology of "design organization" ontology in product design process management, chooses ontology mapping strategy based on classification and finds their ontology mapping relationship. As a result, it supports to realize more efficient share and reuse of product design process knowledge.

2.Product Design Process Ontology

A. The Concept of Product Design Process Ontology

Definition 1(Product design process ontology): Product design process ontology is a kind of detailed characteristic description of the concepts and relationships which abstracted from the design process, and it is the basis of realizing reuse of knowledge in product design process field [2].

Product design process ontology can be defined as $O_{(C_{n},R_{n})}$, in which:

- *o*_denotes product design process ontology;
- *c*_denotes concepts collection of *o*_;
- R denotes relationships collection of O.

B. Product Design Process Ontology Model

1) Construct the relationship of design process ontology

Through the research of product design process, product design process ontology is divided into design process activity ontology, design process tool ontology, design process result ontology, design process regulation ontology, design process standard ontology, design process experience ontology and design process organization ontology. Part of the concepts and their relationships are shown in Fig. 1.

2) Construct the attributive of design process ontology

In the basis of construction of concept and relationship of product design process, gives the attributive definition of them. To the concept of "organization set", defines the attributives of ID, position name, position constitution and storage. To the concept of "QFD figure", defines the attributives of ID, consent, originate, date, publisher, storage and amendments. To the concept of "plan stage", defines the attributives of ID, target, activity, staff, result, storage, and so on.

3) Fill the example of design process ontology

In the basis of construction of relationship and attributive of product design process, fills the example of product design process and forms the part of product design process ontology as shown in Fig. 2.

3.Ontology Mapping

C. Concept of Ontology Mapping

Definition 2(Ontology mapping): Ontology mapping refers to confirming how ontology is mapped or mutually related. During exact mapping process, ontology mapping mainly includes 6 kinds of mapping models: 1:1, 1:n, n:1, 1:null, null:1and n:m [3].

Definition 3(Similarity): The similarity value is among 0 and 1. $Sim(s_1, s_2)$ is similarity between concept s and concept s [4].

• sim(s, s) = 1: denotes concept s and concept s are identical;

• $sim(s_1, s_2) = 0$: denotes concept s_1 and concept s_2 are totally different.

D. Ontology Mapping Based on Classification

Ontology concept mapping based on natural language disposal is very practical to semantic web, and its basic thought is as follows: first, it searches a group of relevant documents as sample document based on ontology concept; second, it constitutes words eigenvector by considering parameters such as appearance frequency of words in document and their relationships with other words; finally, it calculates similarity of concepts based on concepts eigenvector [5].

In order to reduce complexity of similarity calculation, ontology concept mapping method based on classification is brought out, and its basic thought is as follows: dividing ontology database into several small-size ontology trees through classification, and establishing similarity mapping on root node; thus, all similarity calculations are established among classification trees where root node of similarity mapping lies. So, the complexity of concepts similarity calculation is reduced significantly [6-8]. The exact procedures are as follows:

1) Give definition

Basic relationship among concepts is inclusion relationship in ontology database, which is usually described in tree structures. The following definitions are made:

- *o* and *o* are two ontology databases mapped;
- *C* and *C* are leaf concept nodes of ontology databases;
- W and W are classification nodes of ontology databases, and $W \in O$, $W \in O$.

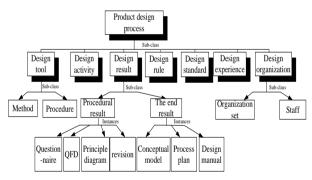


Figure 1. Part of relationship of product design process

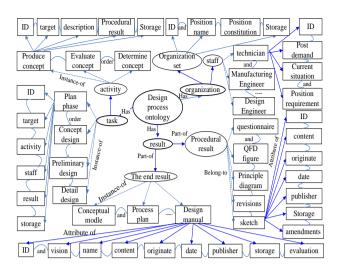


Figure 2. Part of design process knowledge ontology

2) If two classification nodes from the two ontology databases O and O are similar, all nodes included in classification tree Tree and Tree can be mapped.

3) Procedure of similarity calculation

After mapping relationship of classification nodes is acquired, similarity calculation should be carried out on concept nodes in classification tree which guided by mapping classification nodes [9]. The exact procedures and calculation formula are as follows:

• Take cartesian product of all elements $C_i \in Tree_i$ and $C_i \in Tree_i$ as key phrase under classification tree

Tree and *Tree*, search a sample document for each set of key phrases (e.g. Google search, get the first value), and form a collection D, the amount of sample document collection is $K = Number(Tree_i) \times Number(Tree_i)$.

Record appearance frequency of possible mapping pair in each sample document as f_i^k, record appearance frequency of concept C_i in sample document as f_i^k, record appearance frequency of concept C_i in sample document as f_i^k, then similarity calculation formula can be gotten:

$$sim(C_i, C_j) = \sum_{D \in Duciment} \left(\frac{2 \times f_j^k}{f_i^k + f_j^k} \right).$$
(1)

Basic thought of (1) is: appearance frequency of mapping pair of which $sim(C_i, C_j) \ge 0.6$ is higher than that of mapping pair of which $sim(C_i, C_j) \le 0.6$ in sample documents (threshold value of this paper is set to be 0.6, which can be regulated according to actual application field).

4) Concept nodes which can not establish mapping relationship should be calculated according to the traditional similarity calculation method.

4.Design Process Ontology Mapping based on Classification

This paper chooses human resource ontology as the heterogeneous ontology of product design process ontology to establish their semantic ontology mapping relationship.

E. Give Definition

In ontology database, the basic relationship among concepts is inclusion relationship. Describes relationship between product design process management system and human resource management system with tree structure, and the definitions are as follows:

- $O_{\rm is}$ is design process ontology database, $O_{\rm int}$ is human resource ontology database;
- C_i is leaf concept nodes of product design process ontology database, C_j is leaf concept nodes of human resource ontology database, and $C_i \in O_m$, $C_i \in O_{im}$;
- W_i is classification nodes of design process ontology database, and W_j is classification nodes of human resource ontology database, and $W_i \in O_m$, $W_i \in O_{max}$;
- *Tree* is classification tree of product design process, *Tree* is classification tree of human resource management, and $\exists C_i \subset W_i$, $\exists C_i \subset W_i$.

F. Discover Sharing Knowledge

Establishes the Correlation matrix of product design process management and human resource management and discovers their sharing knowledge. Fig. 3 shows that "design organization" ontology in product design process management and "design department" ontology in human resource management is possible sharing knowledge while filer out the not related knowledge.

G. Determine Matching Concepts Set

Takes "design organization" T_{ree_1} and "design department" T_{ree_2} as the example of classification tree. "Design organization" T_{ree_1} comes from design process ontology database O_{pro} and "design department" T_{ree_2} comes from human resource ontology database O_{pro} .

Concepts set of "design organization" *Tree* includes: organization set, ID, position name, position constitution, role kind, design engineer, manufacture engineer, technician, product manager, material expert, name, position demand, current situation and position requirement.

Concepts set of "design department" *Tree*₂ includes: basic attributive, staff ID, name, position, proficiency, position level, position type, design engineer, manufacture engineer, technician, product manager, material expert, state attributive, position constitution, use state and position requirement.

Mapping relationship between "design organization" $Tree_1$ and "design department" $Tree_2$ will be built by experts in the field, as shown in Fig. 4.

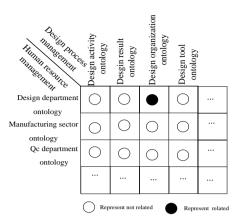


Figure 3. Classification tree of ontology database

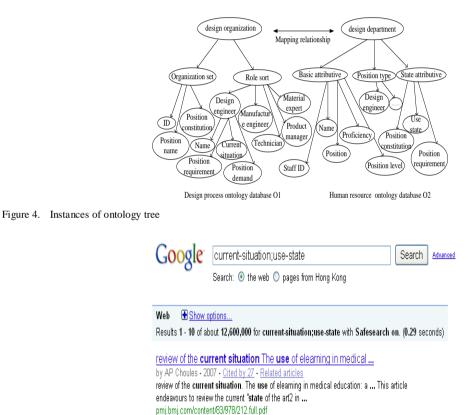


Figure 5. Sample instance of concept mapping documents

H. Mapping Decision

After acquiring matching concepts set between "design organization" and "design department", the paper carries out similarity calculation of concept nodes in classification tree which guided by mapping classification nodes.

Searches a sample document in each possible mapping pairs in "design organization" and "design department" (e.g. Google search, get the first value), and form a sample document collection. Takes (current-situation, usestate) as an example of the mapping pair, exact sample document is shown in Fig. 5.

With appearance frequency of mapping pair(current-situation, use-state)in all sample documents, the paper can acquire appearance frequency f_i^* of concept "current-situation", appearance frequency f_j^* of concept "use-state", and appearance frequency f_i^* of mapping pair (current-situation, use-state) in sample document. Similarly, according to the mapping relationship which experts established, this paper can acquire the appearance frequency (f_i^*, f_j^*, f_{ij}^*) of other possible mapping pairs which from concepts in "design organization" and concept in "design department" as shown in Table I.

2) Calculate similarity value of mapping pairs

According to (1), similarity of mapping pair (current-situation, use-state) can be acquired.

sim(current - situation, use - state) = 0.884

(2)

Similarly, the similarity value of other concept mapping pairs which from "design organization" ontology and "design department" ontology can be acquired.

Table II shows the similarity of mapping pairs which from concepts in "design organization" ontology and the concept "use-state" in "design department" ontology. Table II also shows that possible concept pairs are (current-situation, use-state) and (post-requirement, use-state) when concept similarity threshold value is 0.6. Actually, the meaning of (post-requirement, use-state) can be estimated, so this kind of pseudo-mapping can be eliminated when experts confirm mapping relationship. Thus, the concept pair with maximum similarity is (current-situation, use-state) between the concepts in "design organization" and the concept "use-state" in "design department".

3) Output mapping relationship

Similarly, the paper can acquire other similarity value of possible mapping pairs established by experts and find one of which the similarity value is larger than 0.6. The concept pairs with maximum similarity value in two ontology databases are shown in Table III.As the mass calculation, this paper will not list the calculation procedures any more.

5.Conclusion

In the basis of product design process knowledge ontology model established, this paper chose ontology mapping method based on classification as decision-making strategy; took "design department" ontology in human resource management as heterogeneous ontology of "design organization" ontology in product design process management; found their ontology mapping relationship; adopted similarity calculation method to carry out similarity of part of mapping pairs. Future work focus on the methods of transforming the knowledge denoted in heterogeneous ontology with mapping relationship for efficient share and reuse of product design process knowledge in a broader scope.

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TABLE I. FREQUENCY VALUE OF MAPPING PAIRS

(C_i, C_j)	f_i^k	f_j^k	f_{ij}^{k}
(current-situation, use-state)	23	29	23
(position-name, use-state)	6	12	6
(position-constitution, use-state)	4	9	4
(position-requirement, use-state)	5	11	5
(ID, use-state)	19	24	19
(name, use-state)	9	14	9
(position-demand, use-state)	3	7	3

TABLE II. SIMILARITY VALUE OF MAPPING PAIRS

Concept in O ₁	Concept in O ₂	Sim
current-situation	use-state	0.884>0.600
position-name	use-state	0.421
position-constitution	use-state	0.267
position-requirement	use-state	0.625>0.600
ID	use-state	0.131
name	use-state	0.234
position-demand	use-state	0.465

TABLE III. CONCEPT PAIRS WITH MAXIMUM SIMILARITY

Concept in O ₁	Concept in O ₂	Sim
current-situation	use-state	0.884
role-sort	position-type	0.83
ID	name-ID	0.61
position-requirement	position-requirement	1
position-demand	position-level	0.71
position-constitution	position-constitution	1
design-engineer	design-engineer	1

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